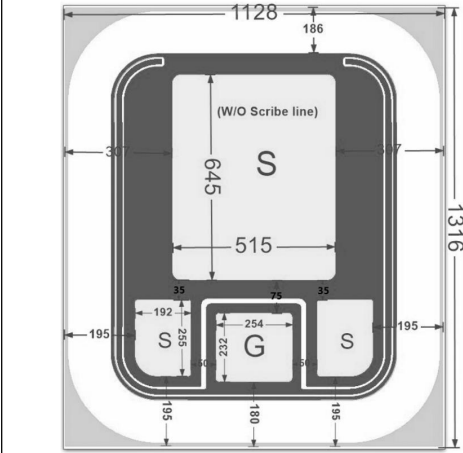
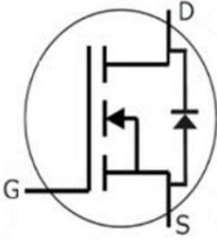


### Physical Characteristics

	<p>Die size: 1128 μm x 1316 μm (without scribe line)          Gate pad: 254 μm x 232 μm          Gross die / per 6" wafer = 9278 pcs</p>	
	<p>Main characteristics:  <math>V_{DS} = 1700V</math>  <math>I_D(T_C=25^\circ C) = 8.7A</math>  <math>R_{DS(on)MAX} = 1.4\Omega@18V</math></p>	

### Mechanical Data

Parameter	Parameter
Nominal Back Metal Composition, Thickness	Ti- Ni - Ag
Nominal Front Metal Composition, Thickness	Al(4μm)
Wafer Diameter	150mm
Wafer Thickness	175μm±10μm
Scribe line width	80μm

### Absolute Maximum Ratings( $T_C=25^\circ C$ , unless otherwise specified)

Parameter	Symbol	Test Condition	Value	Unit
Drain-Source Voltage	$V_{DS}$	$V_{GS} = 0V, I_D = 100\mu A$	1700	V
Gate-Source Voltage	$V_{GSmax}$	AC (f > 1 Hz)	-10/+25	V
Gate-Source Voltage	$V_{GSOP}$	Static	-4/+18	V
Continuous Drain Current	$I_D$	$V_{GS} = 18V, T_C=25^\circ C$	8.7	A
	$I_D$	$V_{GS} = 18V, T_C=100^\circ C$	6	
Pulsed Drain Current	$I_{D,pulse}$	Pulse with $t_p$ limited by $T_{jmax}$ at 1ms	9	A
		Pulse with $t_p$ limited by $T_{jmax}$ at 100μs	16	
Junction Temperature	$T_J$		-55~ +175	°C
Storage Temperature	$T_{STG}$		-55~ +175	°C

Note 1: Assumes a  $R_{th(jc)}$  will be less than 1.6 K/W.

### Electrical characteristics (T<sub>j</sub>=25°C, unless otherwise noted)

Parameter	Symbol	Test Condition	Min.	Typ.	Max.	Unit
<b>Static Characteristics</b>						
Drain-source breakdown voltage	V <sub>(BR)DSS</sub>	V <sub>GS</sub> = 0V, I <sub>D</sub> = 100μA	1700			V
Zero gate voltage drain current	I <sub>DSS</sub>	V <sub>DS</sub> = 1700V, V <sub>GS</sub> = 0V		1	50	μA
Gate-Source leakage current	I <sub>GSS</sub>	V <sub>GS</sub> = 18V, V <sub>DS</sub> = 0V			250	nA
Gate threshold voltage	V <sub>GS(th)</sub>	V <sub>DS</sub> = V <sub>GS</sub> , I <sub>D</sub> = 0.5mA		2.8		V
		V <sub>DS</sub> = V <sub>GS</sub> , I <sub>D</sub> = 0.5mA, T <sub>j</sub> = 175°C		2.0		
Drain-source on-resistance	R <sub>DS(on)</sub>	V <sub>GS</sub> = 18V, I <sub>D</sub> = 2A		0.9	1.4	Ω
		V <sub>GS</sub> = 20V, I <sub>D</sub> = 2A		0.8		
		V <sub>GS</sub> = 20V, I <sub>D</sub> = 2A, T <sub>j</sub> = 175°C		2		
Transconductance	g <sub>fs</sub>	V <sub>DS</sub> = 18V, I <sub>D</sub> = 2A		1		S
		V <sub>DS</sub> = 18V, I <sub>D</sub> = 2A, T <sub>j</sub> = 175°C		0.8		
<b>Dynamic characteristics</b>						
Input Capacitance	C <sub>iss</sub>	V <sub>DS</sub> = 1000V, V <sub>GS</sub> = 0V, f = 1MHz V <sub>AC</sub> = 25mV		168		pF
Output Capacitance	C <sub>oss</sub>			13		
Reverse Transfer Capacitance	C <sub>rss</sub>			2.7		
Total Gate Charge	Q <sub>g</sub>	V <sub>DS</sub> = 1200V, I <sub>D</sub> = 2A V <sub>GS</sub> = -4V/18V		15		nC
Gate-Source Charge	Q <sub>gs</sub>			1.7		
Gate-Drain Charge	Q <sub>gd</sub>			9		
Internal Gate Resistance	R <sub>G(int)</sub>	f = 1 MHz, V <sub>AC</sub> = 25mV		6		Ω
<b>Source-Drain Diode characteristics</b>						
Diode Forward Current	I <sub>S</sub>	V <sub>GS</sub> = -4V, T <sub>C</sub> = 25°C		8		A
Diode Forward voltage	V <sub>SD</sub>	V <sub>GS</sub> = -4V, I <sub>SD</sub> = 1A		3.7		V
		V <sub>GS</sub> = -4V, I <sub>SD</sub> = 1A, T <sub>J</sub> = 175°C		3.3		V
Diode Pulse Current	I <sub>S,pulse</sub>	V <sub>GS</sub> = -4V, pulse width t <sub>p</sub> limited by T <sub>jmax</sub>		9		A